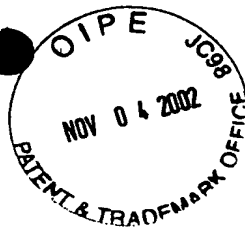


DOCKET NO.: 200089US3



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WB
11/7/02

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :

TOSHIO HASEGAWA :

EXAMINER: VANOY, T. C.

SERIAL NO: 09/718,483 :

FILED: NOVEMBER 24, 2000 :

GROUP ART UNIT: 1754

FOR: EXHAUST APPARATUS FOR
PROCESS APPARATUS AND
METHOD OF REMOVING
IMPURITY GAS :

RECEIVED
NOV-6 2002
JC 1700 MAIL ROOM

AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

In response to the Office Action dated July 2, 2002, please amend the above-identified application as follows:

IN THE SPECIFICATION

Please amend the specification as follows:¹

Please replace the paragraph at page 1, lines 12-17, as follows:

a,
The present invention relates to an exhaust apparatus for a process gas, which is used in combination with a process apparatus for forming a layer on an object to be processed using the process gas, and relates to a method of removing an impurity gas (unprocessed gas, non-reacted process gas) formed by a process gas.

Please replace the paragraph at page 16, lines 10-21, as follows:

¹ A marked-up copy of the amendments is attached hereto.

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a-